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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/626,620	07/25/2003	Paul J. Rudeck	M4065.0567/P567-A	9373
45374 DICKSTEIN S	7590 07/26/2007 HAPIRO LLP		EXAMINER	
1825 EYE STR	REET, NW		SCHILLINGER, LAURA M	
WASHINGTON, DC 20006			ART UNIT	PAPER NUMBER
			2813	
			MAIL DATE	DELIVERY MODE
			07/26/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

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	Application No.	Applicant(s)
3	10/626,620	RUDECK, PAUL J.
Office Action Summary	Examiner	Art Unit
	Laura M. Schillinger	2813
The MAILING DATE of this communication a riod for Reply	ppears on the cover sheet wi	th the correspondence address
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory periors are period for reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the main earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNIC 1.136(a). In no event, however, may a red will apply and will expire SIX (6) MON ute, cause the application to become AB	CATION.  eply be timely filed  THS from the mailing date of this communication.  ANDONED (35 U.S.C. § 133).
atus		
1) Responsive to communication(s) filed on 04	April 2007	
_	nis action is non-final.	
3) Since this application is in condition for allow		are procedution as to the morito is
closed in accordance with the practice under	·	
	· Ex parte Quayle, 1900 C.D	. 11, <del>1</del> 00 O.O. 210.
sposition of Claims		
4) Claim(s) 9-13 and 66 is/are pending in the a	pplication.	
4a) Of the above claim(s) is/are withdr	rawn from consideration.	
5) Claim(s) is/are allowed.		
6) Claim(s) <u>9-13, 66</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and	or election requirement.	
oplication Papers		
9) The specification is objected to by the Exami	ner.	·
	ccepted or b) objected to	by the Examiner.
Applicant may not request that any objection to the	• • •	·
Replacement drawing sheet(s) including the corre		
11) The oath or declaration is objected to by the	•	• • •
ority under 35 U.S.C. § 119		
<u> </u>		
12) Acknowledgment is made of a claim for foreign	gn priority under 35 U.S.C. §	119(a)-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:		
1. Certified copies of the priority docume		
2. Certified copies of the priority docume		· ·
3. Copies of the certified copies of the pr	·	received in this National Stage
application from the International Bure	, , , , , ,	
* See the attached detailed Office action for a li	st of the certified copies not	received.
tachment(s)		
□ Notice of References Cited (PTO-892)	4) Interview S	Summary (PTO-413)
Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s	s)/Mail Date
Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	5) Motice of Ir 6) Other:	nformal Patent Application

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

Claims 9-13 and 66 are rejected under 35 U.S.C. 102(a) as being anticipated by Admitted Prior Art (hereinafter referred to as "APA"- the citations below pertain to Applicant's specification).

APA teaches the following claimed limitations as follows:

9. A memory device comprising:

a substrate (APA - Fig.2A);

a gate stack pair comprising two gate stacks formed on the substrate (APA- Fig.2A and page 3 [0007];

a conductive contact between the two gate stacks and in contact with a doped region of the substrate (page 1 [0003]);

a vertical oxide spacer adjacent to each gate stack of the gate stack pair (Fig.3 (11));

a respective nitride layer overlaying and in contact with each of said vertical oxide spacer and each said gate stack neither of the nitride layers extending to overlay the doped region (APA-Fig. 2C (12) and page 3 [0007]);

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a respective dielectric layer (21) overlaying each of the nitride layer (13), the dielectric layer being spaced from each of the vertical oxide spacer (11) by the nitride layer (13) (Fig.3).

- 10. The memory device of claim 9, wherein said gate stack comprises a floating gate and a control gate (APA- Fig.1 (4 and 6) and page 2 [0006]).
- 1 1. The memory device of claim 9, wherein said vertical oxide spacer is between about 50 A and about 300A in thickness (APA- page 3 [0007]).
- 12. The memory device of claim 11, wherein said vertical oxide spacer is about 100A and about 200A in thickness (APA- page 3 [0007]).
- 13. The memory device of claim 9, wherein said nitride layer has a thickness equal to about one half the width of said vertical oxide spacer (APA compare Fig.2C (11 and 12).
- 66. (New) The memory device of claim 9, wherein the dielectric layer comprises borophosphosilicate glass (Fig.3 (21)).

## Response to Arguments

Applicant's arguments filed 4/4/07 have been fully considered but they are not persuasive. Applicant argues that APA fails to teach a dielectric layer spaced apart from the

vertical oxide spacer- however the Examiner interprets this to occur because nitride layer 13 acts as a spacer between the vertical oxide layer 11 and the dielectric 21.

## Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Laura M. Schillinger whose telephone number is (571) 272-1697. The examiner can normally be reached on M-T, R-F 7:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead, Jr. can be reached on (571) 272-1702. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

7/21/07

Laura M Schillinger Primary Examiner Art Unit 2813